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(54) Apparatus and method for preparing a developer solution.

(57) Apparatus for preparing a developer comprises a mixing bath equipped with means for receiving and mixing an undiluted developer solution and pure water, an ultrasonic densitometer for measuring the developer components contained in the developer in the mixing bath, flow rate controlling means for controlling the supply rate of the undiluted solution and/or pure water into the mixing bath according to the output signal from the ultrasonic densitometer, and a storage tank for receiving and storing the developer containing the developer components at a desired concentration.

The apparatus is used by supplying and mixing an undiluted developer solution and pure water into the mixing bath, measuring the concentration of the

developer components in the developer in the mixing bath by the densitometer, controlling the supply rate of the undiluted developer solution and/or pure water into the mixing bath by inputting the output signal from the densitometer into the flow rate controlling means, to provide developer containing the developer components at a definite concentration in the mixing bath, and supplying the developer to the storage tank and storing it therein.

The preferred developer is aqueous tetramethylammonium hydroxide, prepared from an undiluted solution of 5-40 wt% concentration which is diluted to about 2.4%; this is used for lithography.

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The present invention relates to apparatus for preparing a developer solution and to a method wherein this apparatus is used.

Lithography is used to form the fine patterns required for the production of an LCD (Liquid Crystal Display) or LSI (Large Scale Integration), and a photoresist is used for the lithography. As types of photoresist, there are a positive-working type and a negative-working type of photoresist; since the positive-working type photoresist is particularly excellent in dimensional accuracy and resolving power, the positive-working type is generally used.

An aqueous solution of an inorganic or organic alkali is used as a developer for the positive working type photoresist, but to prevent the occurrence of staining with an alkali metal, an aqueous organic alkali solution, in particular, an aqueous solution of tetramethylammonium hydroxide, is suitably used, and the concentration thereof at use is as low as about 2.4% by weight. However, the concentration of an aqueous solution of tetramethylammonium hydroxide produced as an undiluted developer solution is usually from about 5 to 40% by weight and hence it is necessary upon use to dilute the undiluted developer solution with pure water.

Now, for correctly forming fine patterns, it is important to develop the light-exposed resist with good accuracy and it is necessary for this purpose that the composition of the developer used is strictly controlled at a definite concentration.

Hitherto, the concentration and the composition of the developer are correctly controlled by the developer manufacturer and the developer is prepared by the manufacturer and is supplied to users such as the makers of LSI and LCD. Considering that the concentration of an alkali which is the main component of the developer is about 2.4% by weight as described above but when the undiluted developer solution is obtained as an aqueous solution having a concentration of from about 5 to 40% by weight, there is a problem that when the developer manufacturer supplies the diluted developer solution to the users, the costs for the container and the transportation for transporting the developer from the developer manufacturers to the users increase. To overcome this problem, the developer manufacturer supplies the undiluted developer solution to the users, and the users dilute the undiluted developer solution. However, it is necessary that the concentration of the developer after dilution is strictly adjusted to a definite concentration and that the developer is kept and controlled at that concentration, and also from the standpoint of industrial practice it is required to practice the above procedure quickly and in labor-saving manner.

Even under these circumstances, a developer preparing apparatus and a developer preparing method, which can strictly adjust the concentration

of the developer at a definite value and keep and control the concentration of the developer, and also can practice the procedure quickly and with labor-saving have not yet been realized.

Thus, an object of the present invention is to provide an apparatus and method for preparing a developer, which can strictly adjust the concentration of the developer at a definite value and keep and control the developer at the concentration, and also can practice this procedure quickly and with labor-saving.

We have discovered that the object can be attained by the present invention as described hereinbelow.

According to one embodiment of the present invention, there is provided a developer preparing apparatus for obtaining a developer containing developer components at a definite concentration by mixing an undiluted developer solution with pure water, comprising a mixing bath equipped with a means for receiving and mixing the undiluted developer solution and pure water, an ultrasonic densitometer for measuring the concentration of the developer components contained in the developer in the mixing bath, and flow rate controlling means for controlling the supplying flow rate of the undiluted developer solution and/or pure water into the mixing bath by the output signal from the ultrasonic densitometer, and a storage tank for receiving and storing the developer containing the developer components of the definite concentration in the mixing bath.

According to another embodiment of the present invention, there is provided a developer preparing method for preparing a developer containing developer components of a definite concentration by mixing an undiluted developer solution and pure water, which comprises using the above-described developer preparing apparatus, receiving and mixing the undiluted developer solution and pure water in the mixing bath, measuring the concentration of the developer components contained in the developer in the mixing bath by means of the ultrasonic densitometer, controlling the supplying flow rate of the undiluted developer solution and/or pure water into the mixing bath by putting the output signal from the ultrasonic densitometer in the flow rate controlling means to provide the developer containing the developer components of the definite concentration in the mixing bath, and supplying the developer into the storage tank and storing it therein.

The present invention is described in more detail below.

There is no particular restriction on the developer used in the present invention, but suitable examples of the developer are an aqueous solution of an inorganic alkali and an aqueous solution of an

organic alkali. From the standpoint of capacity of producing recent types of fine LSI, an aqueous organic alkali solution having a very small content of metals is suitable and an aqueous solution of tetramethylammonium hydroxide is particularly preferred. In addition, the undiluted developer solution used in the present invention is obtained as an aqueous solution containing the developer components usually in amount of from 5 to 40% by weight. Also, by diluting the undiluted developer solution with pure water according to the present invention, a developer the concentration of which is strictly adjusted to a definite concentration of about 2.4% by weight is obtained.

The pure water which is preferably used in the present invention is pure water having a metal ion content of not more than a few ppb, and so-called ultra-pure water having a metal ion content of 0.1 ppb or less is more preferred.

In the present invention, there is used a mixing bath equipped with a means for receiving and mixing the undiluted developer solution and pure water. A specific example thereof is a mixing bath having an inlet for the undiluted developer solution, an inlet for pure water, and a stirring means.

Examples of the stirring method are a method of using a stirrer fitted inside the mixing bath, a method of drawing out a part of the developer in the mixing bath by a pump and circulating it into the mixing bath again, and a method of disposing a line mixer in the circulating line in the above circulating method. Furthermore, before supplying the undiluted developer solution and pure water into the mixing bath, they are mixed in a mixing apparatus such as a line mixer and thereafter the mixture may be supplied into the mixing bath. This method is preferable from the standpoint that the concentration of the developer in the mixing bath becomes uniform.

In the present invention, an ultrasonic densitometer is used to measure the concentration of the developer components contained in the developer in the mixing bath. There is no particular restriction on the ultrasonic densitometer and any ultrasonic densitometer which can correctly measure the concentration of the developer components can be used. For example, it is preferred that the frequency used is several MHz, the liquid-contact portion is composed of SUS (stainless steel) or a fluorine-containing polymer such as ptfe (e.g. Teflon, trade mark of E.I. du Pont de Nemours & Co., Ltd.), and the ultrasonic densitometer is equipped with a temperature-measuring portion and an ultrasonic wave transmitting and receiving portion, and also is equipped with a function capable of automatically correcting the measurement value to the temperature at measurement by the calibration curve previously obtained using a devel-

oper having a predetermined concentration and a temperature change compensating apparatus.

The ultrasonic densitometer used in the present invention must have a function capable of transmitting the measured value as an output signal. This is because it is necessary to control the supplying flow rate of the undiluted developer solution and/or pure water to the mixing bath by means of the output signal.

The measurement terminal of the ultrasonic densitometer may be disposed in the developer in the mixing bath, may be disposed in the above-described circulation line, or may be disposed in a measuring sampling line for sampling a small amount of the developer in the mixing bath and recycling it into the mixing bath.

In the present invention, it is necessary to use a flow rate-controlling means for controlling the supplying flow rate of the undiluted developer solution and/or pure water into the mixing bath by the output signal from the ultrasonic densitometer. There is no particular restriction on the type of flow rate controlling means; a means having a function of controlling the supplying flow rate of the undiluted developer solution and/or pure water into the mixing bath in accordance with the deviation between the concentration of the developer components in the developer in the mixing bath obtained as the output signal from the ultrasonic densitometer and the desired concentration of the developer components may suitably be used. Also, by providing a load cell for detecting the weight of the developer in the mixing bath and by controlling the supplying flow rate of the undiluted developer solution and/or pure water into the mixing bath based on the signal corresponding to the weight thereof and the deviation described above, a more precise and rapid automatic preparation of the developer becomes possible.

The developer mixed in the mixing bath, i.e. having the developer components of the definite concentration obtained by the method described above, is then stored in the storage tank and, when needed, is taken out from the storage tank for use.

The portions of the apparatus of the present invention which are contacted with the developer are preferably composed of a fluorine resin such as ptfe., a polyolefin series resin, or a material coated with the above-described resin, so as to prevent the contamination of the developer by traces of a metal.

The present invention is illustrated by the following example.

Example

A mixing bath vessel having a volume of 1 m³ and having a stirrer was provided. The inside por-

tion of the mixing bath and the portion of the stirrer to be contacted with the developer were all made of ptfe. Each supply line for the undiluted developer solution and pure water was a ptfe pipe and both lines were united with each other before entering the mixing bath and thereafter, the united line was connected to the mixing bath through a line mixer. Each of the supplying lines of the undiluted developer solution and pure water into the mixing bath was equipped with a flow rate control valve as means for controlling the flow rate and each flow rate control valve could control the flow rate of the undiluted developer solution or pure water according to the output signal from the ultrasonic densitometer. The ultrasonic densitometer was disposed in the line for taking out a part of the developer in the mixing bath, and the developer after the concentration thereof was measured was recycled into the mixing bath. Also, an inlet line was fitted to the mixing bath, whereby the developer thus prepared could be sent to the storage tank.

As the undiluted developer solution, an aqueous solution of about 15% by weight of tetramethylammonium hydroxide was used. After mixing the undiluted developer solution and pure water by the above-described line mixer, the mixture was supplied into the mixing bath. The stirrer of the mixing bath was rotated and the mixture supplied in the mixing bath was thus sufficiently stirred and mixed in the mixing bath.

Part of the developer in the mixing bath was sent to the line in which the ultrasonic densitometer was disposed, wherein the concentration of tetramethylammonium hydroxide in the developer was measured and at the same time, the output signal from the ultrasonic densitometer was sent to the flow rate controlling means of each of the supplying lines of the undiluted developer solution and pure water through a controller, and by automatically controlling the extent to which the flow rate control valves were open, the flow rates of the undiluted developer solution and pure water were controlled.

As a result thereof, the concentration of the developer in the mixing bath was maintained at 2.381% by weight for the operation period of 30 minutes and over the total prepared amount by volume of 0.8 m³, which showed that the developer could be prepared within an error of 0.04% to the desired concentration of 2.380% by weight. Furthermore, during the procedure the operation was all automated, and thus the method of the present invention was very excellent for labor-saving.

As described above, by the present invention we provide an apparatus and method for preparing a developer which can strictly prepare the developer at a definite value and keep and control the developer at the desired concentration, and also

can operate quickly and with labor-saving.

Claims

- 5 1. Apparatus for preparing a developer so as to obtain a developer containing developer components having a definite concentration by mixing an undiluted developer solution and pure water, comprising a mixing bath equipped with a means for receiving and mixing an undiluted developer solution and pure water, an ultrasonic densitometer for measuring the developer components contained in the developer in the mixing bath, a flow rate controlling means for controlling the supplying flow rate of the undiluted developer solution and/or pure water into the mixing bath according to the output signal from the ultrasonic densitometer, and a storage tank for receiving from the mixing bath and storing the developer containing the developer components having the definite concentration.
- 10 2. Apparatus as claimed in Claim 1, which includes a load cell for detecting the weight of the developer in the mixing bath.
- 15 3. A method of preparing a developer containing developer components having a definite concentration by mixing an undiluted developer solution and pure water, which comprises using the developer preparing apparatus of Claim 1 or 2, supplying and mixing an undiluted developer solution and pure water in the mixing bath, measuring the concentration of the developer components contained in the developer in the mixing bath by the ultrasonic densitometer, controlling the supplying flow rate of the undiluted developer solution and/or pure water into the mixing bath by inputting the output signal from the ultrasonic densitometer to the flow rate controlling means to provide the developer containing the developer components of a definite concentration in the mixing bath, and supplying the developer to the storage tank and storing it therein.
- 20 4. A method as claimed in Claim 3, wherein the output signal from the ultrasonic densitometer and the output signal from the load cell are inputted into the flow rate controlling means.
- 25 5. The apparatus of Claim 1 or developer preparing method of Claim 3 or 4, wherein the undiluted developer solution is an aqueous solution of tetramethylammonium hydroxide.
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6. A diluted developer solution prepared by the method of Claim 3, 4 or 5.

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EUROPEAN SEARCH REPORT

Application Number
EP 93 30 8875

DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int.Cls)
Y	DE-A-40 03 119 (KABUSHIKI KAISHA TOSHIBA) * column 3, line 19 - line 62; figure 1 * ---	1-6	G03F7/30
Y	DATABASE INSPEC INSTITUTE OF ELECTRICAL ENGINEERS, STEVENAGE, GB Inspec No. 2343545 DRESS W B 'A high resolution ultrasonic densitometer' * abstract * & 1983 ULTRASONICS SYMPOSIUM PROCEEDINGS, ATLANTA, GA, USA, 31 OCT.-2 NOV. 1983, 287 - 290 VOL.1 ---	1-6	
Y	PATENT ABSTRACTS OF JAPAN vol. 8, no. 103 (E-244)(1540) 15 May 1984 & JP-A-59 021 022 (NIPPON ZEON K. K.) * abstract * ---	2	
P,X	PATENT ABSTRACTS OF JAPAN vol. 17, no. 658 (P-1654)6 December 1993 & JP-A-05 216 241 (MITSUBISHI GAS CHEM CO INC) 27 August 1993 * abstract * ---	1,2	TECHNICAL FIELDS SEARCHED (Int.Cls) G03F
A	PATENT ABSTRACTS OF JAPAN vol. 13, no. 208 (C-596)16 May 1898 & JP-A-01 027 624 (HITACHI PLANT ENG & CONSTR) 30 January 1989 * abstract * ---	1-6	
Y	PATENT ABSTRACTS OF JAPAN vol. 014, no. 207 (P-1043)26 April 1990 & JP-A-02 046 464 (SEIKO EPSON CORP) 15 February 1990 * abstract * --- -/--	5,6	
The present search report has been drawn up for all claims			
Place of search THE HAGUE		Date of completion of the search 14 April 1994	Examiner Barathe, R
CATEGORY OF CITED DOCUMENTS X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons * : member of the same patent family, corresponding document			



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EUROPEAN SEARCH REPORT

Application Number
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DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int.Cl.5)
L	EP-A-0 578 505 (TOKYO OHKA KOGYO CO., LTD.) * column 4, line 16 - line 37; figure * -----	1-6	
			TECHNICAL FIELDS SEARCHED (Int.Cl.5)
The present search report has been drawn up for all claims			
Place of search THE HAGUE		Date of completion of the search 14 April 1994	Examiner Barathe, R
CATEGORY OF CITED DOCUMENTS			
X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document		T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons ----- & : member of the same patent family, corresponding document	